



INTERNATIONAL
GEMOLOGICAL
INSTITUTE

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LABORATORY GROWN DIAMOND REPORT

June 18, 2026

IGI Report Number

DESCRIPTION

Shape and Cutting Style

Measurements

GRADING RESULTS

Carat Weight

Color Grade

Clarity Grade

ADDITIONAL GRADING INFORMATION

Polish

Symmetry

Fluorescence

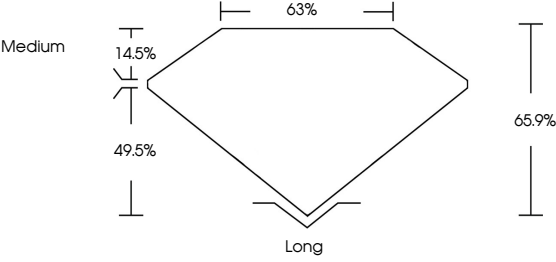
Inscription(s)

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa

LG811682410

Report verification at [igi.org](https://www.igi.org)

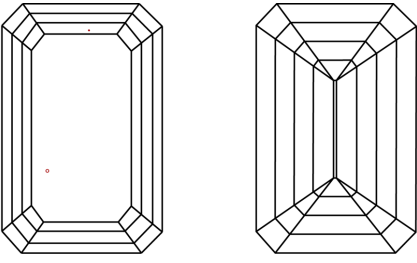
PROPORTIONS





Sample Image Used

CLARITY CHARACTERISTICS



KEY TO SYMBOLS

Red symbols indicate internal characteristics.
Green symbols indicate external characteristics.

COLOR

D E F G H I J

Faint

Very Light

Light

CLARITY

FL IF VVS¹⁻² VS¹⁻² SI¹⁻² I¹⁻³

Flawless Internally Flawless Very Very Slightly Included Very Slightly Included Slightly Included Included

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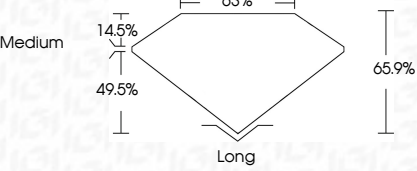
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PROPORTIONS



IGI

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IGI Report No LG811682410

EMERALD CUT

8.08 X 5.39 X 3.55 MM

Carat Weight

Color Grade

Clarity Grade

Table

Depth

Girdle

Culet

Polish

Symmetry

Fluorescence

Inscription(s)

1.53 CARAT

E

VS 1

65.9%

63%

Medium

Long

EXCELLENT

EXCELLENT

NONE

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